UNITED STATES PATENT AND TRADEMARK OFFICE **CERTIFICATE OF CORRECTION**

PATENT NO.

: 7.176.118 B2

Page 1 of 1

APPLICATION NO.: 10/810779

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INVENTOR(S)

: Cem Basceri et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Col. 2, line 30 -

Replace "FIG. 2 is view of the FIG. 1 wafer fragment shown at a" With -- FIG. 2 is a view of the FIG. 1 wafer fragment shown at a --

Col. 3, line 2 -

Replace "from the fluid, The chemical reaction can be selective for an" With -- from the fluid. The chemical reaction can be selective for an-

Col. 3, line 15 –

Replace "new pattering methods are utilized to form nanodevices," With --new patterning methods are utilized to form nanodevices,--

Col. 7, line 13 –

Replace "FIG. 7 is an a sense an opposite to that described with" With --FIG. 7 is in a sense an opposite to that described with--

Signed and Sealed this

Twelfth Day of June, 2007

JON W. DUDAS Director of the United States Patent and Trademark Office